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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/731,144	12/10/2003	Sang Wook Ryu	P69368US0	4774	
136	7590 10/04/2004		EXAM	EXAMINER	
JACOBSON HOLMAN PLLC			DANG, TRUNG Q		
400 SEVENT SUITE 600	H STREET N.W.		ART UNIT	PAPER NUMBER	
WASHINGTON, DC 20004			2823	-	

DATE MAILED: 10/04/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

			UA				
	Application No.	Applicant(s)					
	10/731,144	RYU, SANG WO	OK				
Office Action Summary	Examiner	Art Unit					
	Trung Dang	2823					
The MAILING DATE of this comm Period for Reply	unication appears on the cover sh	eet with the correspondence ac	dress				
A SHORTENED STATUTORY PERIOD THE MAILING DATE OF THIS COMML - Extensions of time may be available under the provisi after SIX (6) MONTHS from the mailing date of this cc - If the period for reply specified above is less than thirt - If NO period for reply is specified above, the maximum - Failure to reply within the set or extended period for re Any reply received by the Office later than three mont earned patent term adjustment. See 37 CFR 1.704(b)	INICATION. ons of 37 CFR 1.136(a). In no event, however, immunication. y (30) days, a reply within the statutory minimur n statutory period will apply and will expire SIX (pply will, by statute, cause the application to be ns after the mailing date of this communication,	may a reply be timely filed n of thirty (30) days will be considered time (6) MONTHS from the mailing date of this come ABANDONED (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s)	filed on .						
2a)☐ This action is FINAL .	2b)⊠ This action is non-final.						
3) Since this application is in condition	•	I matters, prosecution as to the	e merits is				
closed in accordance with the pra	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4) Claim(s) 1-11 is/are pending in the	e application.						
4a) Of the above claim(s) is	lare withdrawn from consideration	n.					
5) Claim(s) 4-11 is/are allowed.							
6)⊠ Claim(s) <u>1-3</u> is/are rejected.							
7) Claim(s) is/are objected to							
8) Claim(s) are subject to res	triction and/or election requireme	nt.					
Application Papers							
9)☐ The specification is objected to by	the Examiner.						
10) The drawing(s) filed on is/a	0) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any ol	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) includ	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)☐ The oath or declaration is objected	I to by the Examiner. Note the att	ached Office Action or form P	TO-152.				
Priority under 35 U.S.C. § 119							
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)⊠ All b)□ Some * c)□ None of	:						
1.⊠ Certified copies of the prior	ty documents have been receive	d.					
2. Certified copies of the prior	ity documents have been receive	d in Application No					
3. Copies of the certified copie	es of the priority documents have	been received in this National	Stage				
application from the Interna	tional Bureau (PCT Rule 17.2(a))).					
* See the attached detailed Office ac	tion for a list of the certified copie	s not received.					
America (C.)							
Attachment(s) 1) ☑ Notice of References Cited (PTO-892) 4) ☐ Interview Summary (PTO-413)							
 Notice of References Cited (P10-692) Notice of Draftsperson's Patent Drawing Review 	(PTO-948) +) □ Inte	per No(s)/Mail Date					
3) Information Disclosure Statement(s) (PTO-1449 Paper No(s)/Mail Date		ice of Informal Patent Application (PTeer:	O-152)				

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by Rostoker (US Pat. 5,662,768).

With reference to Figs. 1a to 1f, the reference anticipates the claims in that it discloses a method of forming a trench in a semiconductor device, comprising:

- (a) a step of depositing a first pad film and a second pad film on a semiconductor substrate (col. 5, lines 8-14);
- (b) a step of pattering the first pad film and the second pad film to expose the semiconductor substrate (Fig. 1a);
- (c) a step of implanting Ar ions to the exposed semiconductor substrate to cause lattice defects in an area of the semiconductor substrate into which the ions are implanted through the ion implanting process;
- (d) a step of performing an etching process using a trench etching mask, wherein the area of the semiconductor substrate in which the lattice defects are

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caused in the step of (c) is etched more rapidly than an area in which the lattice defects are not caused, thereby forming the trench (col. 6, lines 1-15; lines 51-63).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over Rostoker as above in view of Yamazaki et al. (US Pat. 5,641,380).

This rejection is made with regard to the inert gases other than Ar as recited in the claim.

Rostoker teaches the method as described above. Rostoker differs from the claim in that while Rostoker implants an inert gas of Ar to cause lattice damage to the implanted semiconductor region, the claim calls for the use of other inert gases such as He, Ne, Kr, or Xe to effectuate the same. Yamazaki in column 2, lines 37-43 teaches implanting inert gas such as Ar, He, Xe, or Kr converts crystalline silicon into amorphous silicon (i.e., crystalline silicon lattice is damaged). The subject matter as a whole would have been obvious to one having ordinary skill in the art at the time the invention was made to implant He, Xe, or Kr in the process of Rostoker

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so as to cause lattice damage to the implanted semiconductor region because the substitution of art recognized equivalents as shown by Yamazaki would have been within the level of one skilled in the art. As for Ne, one of ordinary skill in the art would reasonably expect the same result because Ne is in the same group in the periodic table with the other inert gases.

- 5. Claims 4-11 are allowed.
- 6. The following is an examiner's statement of reasons for allowance:

Claim 4 and its dependent claims are allowed over prior art of record because the prior art does not teach or suggest the claimed features regarding the steps of performing a first implantation to the substrate exposed between spacers then decreasing the thickness of the spacers thereby increasing the line-width, and then performing a second implantation.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is 571-272-1857. The examiner can normally be reached on Mon-Friday 9:30am-6:00pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Trung Dang Primary Examiner Art Unit 2823

9/30/04